


## Article

# Tuning Sn-Cu Catalysis for Electrochemical Reduction of CO<sub>2</sub> on Partially Reduced Oxides SnOx-CuOx-Modified Cu Electrodes

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**Abstract:** Copper-based bimetallic catalysts have been recently showing promising performance for the selective electrochemical reduction of CO<sub>2</sub>. In this work, we successfully fabricated the partially reduced oxides SnOx, CuOx modified Cu foam electrode (A-Cu/SnO<sub>2</sub>) through an electrodeposition-annealing-electroreduction approach. Notably, in comparison with the control electrode (Cu/SnO<sub>2</sub>) without undergoing annealing step, A-Cu/SnO<sub>2</sub> exhibits a significant enhancement in terms of CO<sub>2</sub> reduction activity and CO selectivity. By investigating the effect of the amount of the electrodeposited SnO<sub>2</sub>, it is found that A-Cu/SnO<sub>2</sub> electrodes present the characteristic Sn-Cu synergistic catalysis with a feature of dominant CO formation (CO faradaic efficiency, 70~75%), the least HCOOH formation (HCOOH faradaic efficiency, <5%) and the remarkable inhibition of hydrogen evolution reaction. In contrast, Cu/SnO<sub>2</sub> electrodes exhibit a SnO<sub>2</sub> coverage-dependent catalysis—a shift from CO selectivity to HCOOH selectivity with the increasing deposited SnO<sub>2</sub> on Cu foam. The different catalytic performance between Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> might be attributed to the different content of Cu atoms in SnO<sub>2</sub> layer, which may affect the density of Cu-Sn interface on the surface. Our work provides a facile annealing-electroreduction strategy to modify the surface composition for understanding the metal effect towards CO<sub>2</sub> reduction activity and selectivity for bimetallic Cu-based electrocatalysts.

**Keywords:** electrochemical reduction of CO<sub>2</sub>; tin oxide-modified copper electrode; electrodeposition; annealing treatment

## 1. Introduction

Conversion of CO<sub>2</sub> to valuable chemicals has been considered as a prospective way to reduce net CO<sub>2</sub> emission and promote utilization of waste gas as well [1,2]. Among present approaches, electrochemical reduction of CO<sub>2</sub> (ERC) is of particular interest, since with renewable electricity as an input, CO<sub>2</sub> and water could be converted in a sustainable fashion into fuels and chemicals under mild conditions [3,4]. However, the viability of electrochemical conversion of carbon dioxide is currently restricted by the lack of inexpensive, efficient, selective and stable electrocatalysts.

To date, the majority of studies have focused on copper, aroused by a report from Hori and Suzuki that demonstrated methane and ethylene as the dominant products from CO<sub>2</sub> reduction on a copper electrode. Cu nanofoam, Cu nanowire and oxide-derived copper (OD-Cu) have been developed for

aqueous ERC [5–10]. However, there are still many problems to be addressed, such as competition with hydrogen evolution reaction (HER) and low selectivity towards a desired product. Experimental and theoretical studies have revealed that the selectivity of Cu can be tuned by introducing a secondary component, such as indium (In), tin (Sn) and sulfur (S) [11–14].

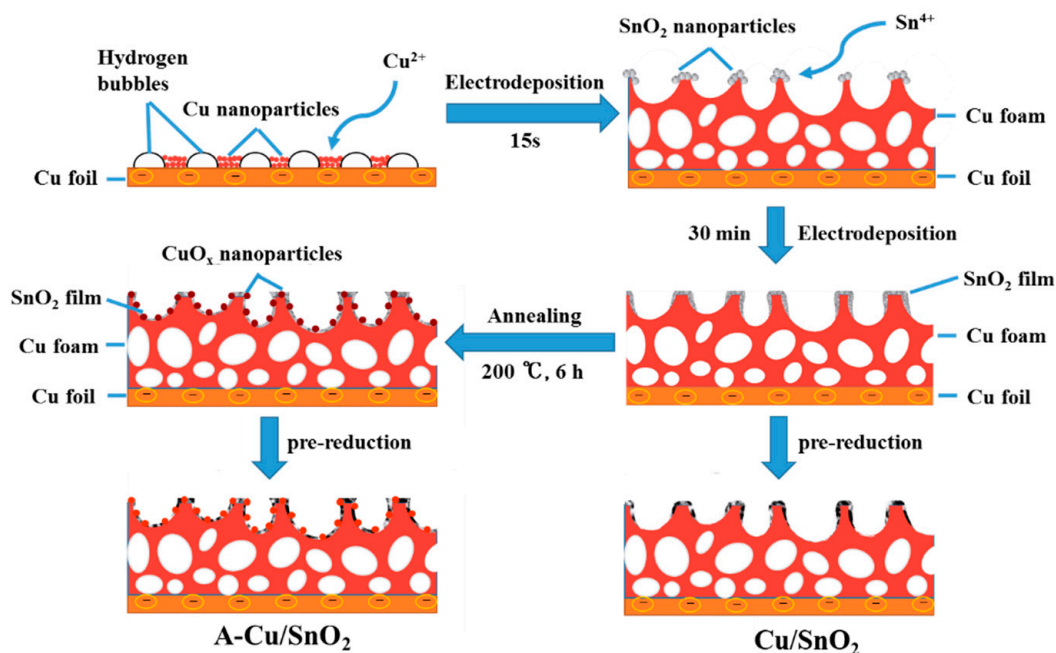
Sn has been preferably chosen to fabricate copper-based hybrid electrocatalysts due to its high hydrogen evolution overpotential, low cost and non-toxicity [15]. Takanahe et al. [16] reported that an electrode with the electrodeposited Sn on OD-Cu shows a high selectivity to CO with a CO faradaic efficiency ( $FE_{CO}$ ) over 90%, which is attributed to the generation of a Sn-Cu surface significantly inhibiting adsorbed  $H^*$ . Meanwhile, Wang et al. [17] developed a catalyst with Sn nanoparticle on copper oxide  $Cu_xO$  nanowire toward the high  $FE_{CO}$  at an optimal coverage of Sn nanoparticles. Recently, a Sn-Cu electrode consisting of dendritic Cu core and a partially reduced oxides  $CuO_x/SnO_x$  shell also achieved excellent  $FE_{CO}$  with a maximum of 94% due to the sparse Sn specie [18]. In contrast, some Sn-Cu electrodes generate formate as the dominant product [19–23]. For example, an electrode with spiky Cu@Sn nanocones over Cu foam exhibits an outstanding  $FE_{HCOOH}$  of 90.4%. Besides this, Wang et al. reported that  $FE_{HCOOH}$  on a porous Sn/Cu electrode can reach up to 91.5%. For understanding the selectivity to CO and formate on Sn-Cu electrodes in ERC, Sun et al. [24] have demonstrated a strategy of controlling the synergistic effect between Cu and  $SnO_2$  in the core/shell structure. They found that the thicker  $SnO_2$  shell acts like the  $SnO_2$  nanoparticle catalysis for the formation of formate, whereas the thinner  $SnO_2$  shell is selective to the formation of CO, attributed to the coexistence of uniaxial compression and Cu atoms on the  $SnO_2$  surface or subsurface. However, there is still a need for extensive study for understanding the Sn effects for the Sn-Cu based electrocatalysts.

In this work, we use the partially reduced oxides  $SnO_x$ ,  $CuO_x$  modified Cu electrode to investigate the Sn-Cu catalysis towards  $CO_2$  reduction activity and selectivity. The  $SnO_2$ -decorated Cu foam electrode Cu/ $SnO_2$  is fabricated through electrodepositing  $SnO_2$  film on porous copper foam followed by electrochemical pre-reduction. Through applying an additional annealing step, the A-Cu/ $SnO_2$  electrode is constructed. Following the above strategy but changing the depositing time of  $SnO_2$ , the electrodes with a different amount of deposited  $SnO_2$  are prepared. Furthermore, the effect of Cu and Sn on  $CO_2$  reduction activity and product selectivity could be discussed based on their performance for electrochemical reduction of  $CO_2$ .

## 2. Results and Discussion

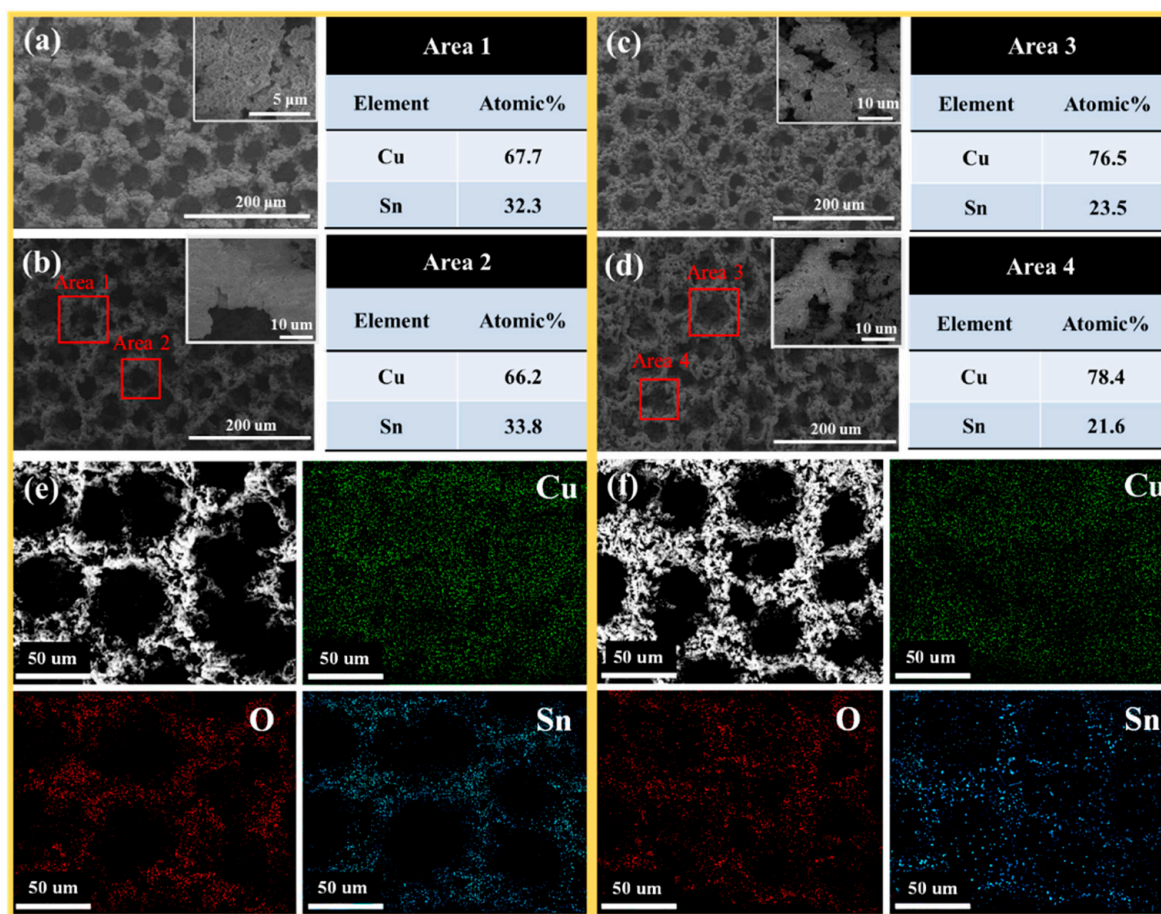
### 2.1. Fabrication and Characterization of Cu/ $SnO_2$ and A-Cu/ $SnO_2$ Electrodes

As shown in Figure 1, Cu foam was electrodeposited on Cu foil in an acidic  $CuSO_4$  solution at a current density of  $-3\text{ A cm}^{-2}$  for 15 s using hydrogen bubbles as a dynamic template. The Cu/ $SnO_2$  electrode was obtained by performing electrodeposition in the  $SnCl_4$  electrolyte for 30 min followed by the electroreduction treatment in a  $CO_2$ -saturated 0.1 M  $KHCO_3$  solution at  $-0.5\text{ V}$  vs. reversible hydrogen electrode (RHE) for an hour. For obtaining the A-Cu/ $SnO_2$  electrode with coexisting copper oxides in  $SnO_2$  layer, annealing procedure ( $200\text{ }^\circ\text{C}$  for 6 h in a muffle furnace) was applied along with the above electrodeposition and electroreduction procedures. After electroreduction under the applied potential in this work, the partially reduced tin oxides,  $SnO_x$ , or partially reduced copper oxides,  $CuO_x$ , could form on Cu foam, which would provide the catalytic sites for electrochemical reduction of  $CO_2$ .



**Figure 1.** Schematic drawing of the fabrication of Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub>.

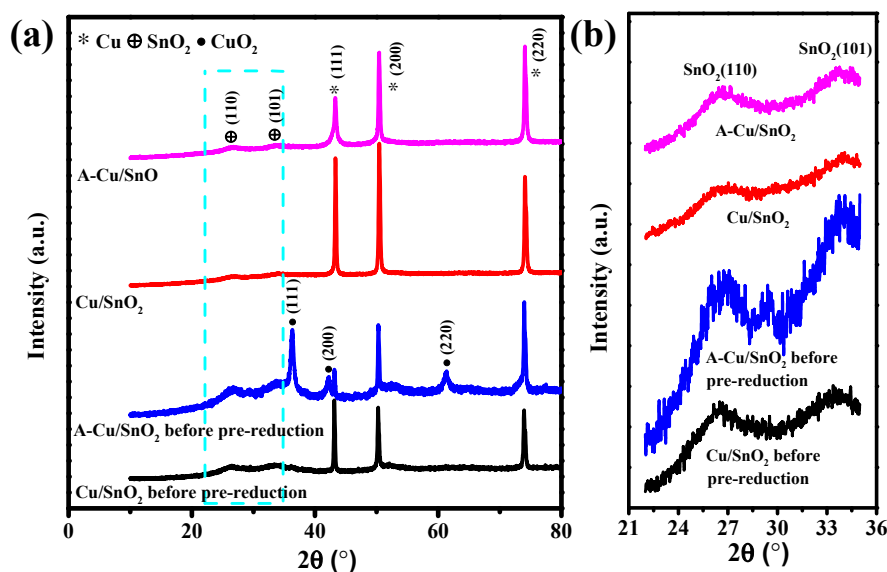
The SEM images at each stage for Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> are shown in Figure 2 and Figures S1–S3. The three-dimensional dendritic Cu foam (Figure S1) with about 40 µm pore size was successfully constructed, which could provide a large electrochemical surface area [5]. After depositing SnO<sub>2</sub> layer on Cu foam (Figure 2a) and then performing pre-reduction, the resultant Cu/SnO<sub>2</sub> electrode (Figure 2b) ideally maintains the porous structure and shows a thin layer consisting of numerous packed flakes covering the original copper dendrites. The cross-sectional view (Figure S2) indicates that the thickness of Cu foam and deposited SnO<sub>2</sub> layer on Cu foil is 60–70 µm. Furthermore, through above procedure but adding an annealing step before pre-reduction, A-Cu/SnO<sub>2</sub> electrode was obtained. Figure 2c,d show the morphology for A-Cu/SnO<sub>2</sub> at the stage of annealing and pre-reduction, respectively. Obviously, A-Cu/SnO<sub>2</sub> displays the same porous structure, but with a significant increase of Cu atoms on the surface (EDS: 76.5%, 78.4%) compared with Cu/SnO<sub>2</sub> (EDS: 66.2%, 66.7%). In addition, the SEM elemental mapping of Cu and Sn for the Cu/SnO<sub>2</sub> electrode before and after pre-reduction (Figure S3a and Figure 2e) reveals that SnO<sub>2</sub> is mainly electrodeposited on the outer Cu walls of the porous structure, forming a connecting film on the surface. Whereas, from the SEM elemental mapping of A-Cu/SnO<sub>2</sub> at the stage of annealing and pre-reduction (Figure S3b and Figure 2f), it can be seen that Sn atoms distribute both inward pores and the outward pores, indicating the re-distribution of SnO<sub>2</sub> during preparation. Besides this, ICP-AES results for Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> (Table S1) reveals that there is no missing Sn atom due to annealing treatment. Together with above results, we could speculate that there is a significant migration of Cu and Sn atoms for the A-Cu/SnO<sub>2</sub> electrode due to annealing, leading to the enrichment of Cu atoms and a decrease of Sn atoms on the surface, which is also confirmed by XPS analysis (Table S2). Moreover, the structure of the deposited SnO<sub>2</sub> film (inset images of Figure 2a–c) shows that there is a slight breakage of SnO<sub>2</sub> film after annealing treatment, which might be caused by the formation of copper oxides as well as migration of SnO<sub>2</sub> inward to the holes.



**Figure 2.** Typical SEM images of (a) Cu/SnO<sub>2</sub> before pre-reduction; (b) Cu/SnO<sub>2</sub>; (c) A-Cu/SnO<sub>2</sub> before pre-reduction; (d) A-Cu/SnO<sub>2</sub>. SEM elemental mapping of (e) Cu/SnO<sub>2</sub> and (f) A-Cu/SnO<sub>2</sub>. The table is EDX analysis identifying.

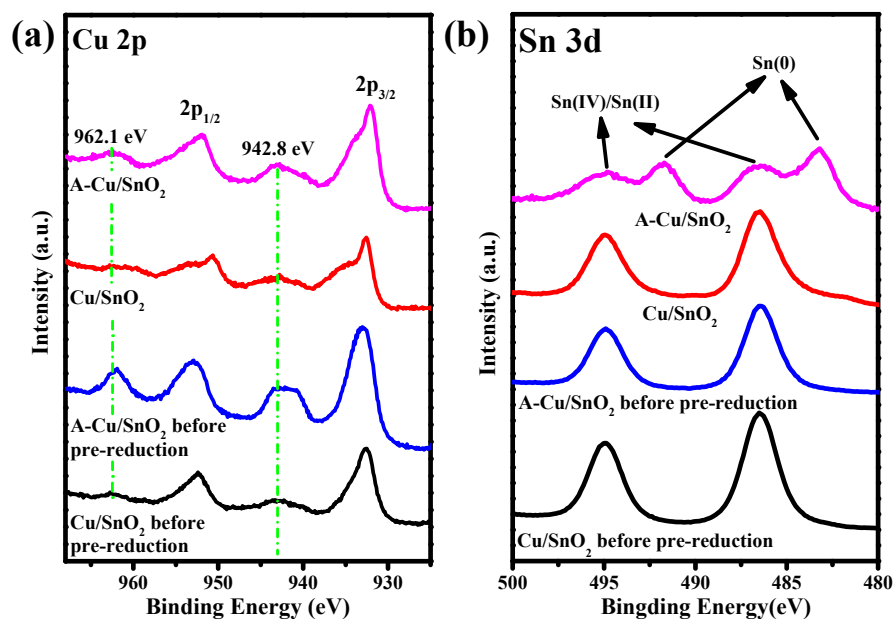
Figure S4 and Figure 3a give the XRD patterns of the samples at each fabrication step. Similar to Cu foil, Cu foam (Figure S4) also exhibits three distinct peaks assigned to Cu (JCPDS 04–0836). For the Cu/SnO<sub>2</sub> electrode, it shows the same diffraction peaks before and after the electrochemical pre-reduction—two broad peaks at 26.6° and 33.9° assigned to (110) and (101) planes of the deposited SnO<sub>2</sub> (JCPDS 41–1445) besides the diffraction peaks of Cu. In contrast, for the A-Cu/SnO<sub>2</sub> electrode before the pre-reduction treatment, three obvious peaks at 36.4°, 42.3° and 61.3° ascribed to (111), (200) and (220) planes of Cu<sub>2</sub>O (JCPDS 65–3288) appear along with the relatively decreased intensity of the Cu(111) peak, suggesting the formation of Cu<sub>2</sub>O particles through annealing at 200 °C for 6 h. Obviously, the as-prepared A-Cu/SnO<sub>2</sub> shows the absence of Cu<sub>2</sub>O peaks, which indicates the reduction of Cu<sub>2</sub>O during electrochemical pre-reduction, leading to the formation of partially reduced copper oxides. Besides this, an intensity increase of SnO<sub>2</sub> diffraction peaks is observed for the electrode with the annealing step from Figure 3b, indicating the improved crystallinity of SnO<sub>2</sub> due to heat treatment. Obviously, the Sn-Cu oxides-modified Cu foam is achieved through facile annealing step.





**Figure 3.** (a) XRD patterns of Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> before and after pre-reduction; (b) XRD peak position of SnO<sub>2</sub> (inset).

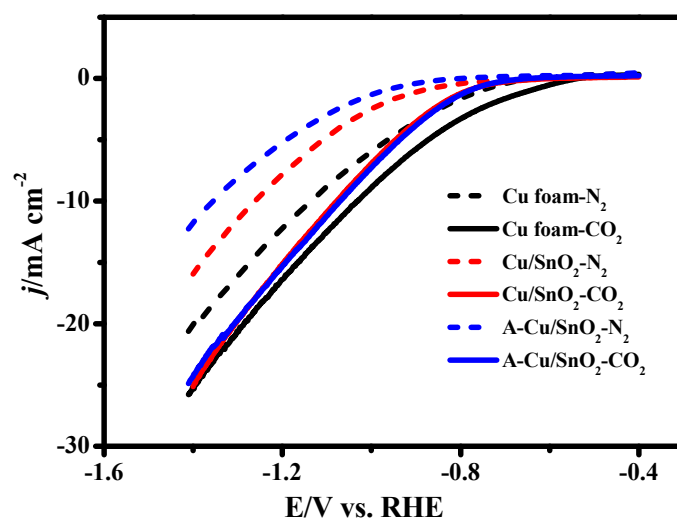
To confirm the chemical states of Cu and Sn for Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub>, X-ray photoelectron spectroscopy (XPS) analyses were performed. For comprehensive comparison, the samples of Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> without pre-reduction treatment are also analyzed. XPS survey spectra are shown in Figure S5. Figure 4a shows the high-resolution Cu 2p spectra. It can be seen that they all present the typical four peaks, which could be assigned to the mixed oxidation states of copper [8,9,17]. This result is not entirely consistent with XRD patterns (Figure 3). Since XPS is a surface-sensitive analysis, a trace amount of copper oxide presenting on the surface due to the air oxidation during storage is detected but is not observed in XRD. Similarly, CuO is not detected in XRD but can be identified by XPS. Notably, it is obvious that A-Cu/SnO<sub>2</sub> displays increased Cu(II) satellite peaks at 942.8 and 962.1 eV in comparison with those of Cu/SnO<sub>2</sub>, and the intensity increase is significant even before pre-reduction, indicating the formation of a significant amount of copper oxides on the surface during annealing. This is further confirmed by the quantitative analysis (Table S2) that the atomic percent of Cu is 26.0% for A-Cu/SnO<sub>2</sub> and 17.1% for Cu/SnO<sub>2</sub>. In addition, it is observed that the electroreduction treatment leads to a remarkable intensity decrease of peaks assigned to copper oxide species for A-Cu/SnO<sub>2</sub>, suggesting the occurrence of the reduction reactions. As a result, partially reduced oxides CuO<sub>x</sub> could appear on the surface of A-Cu/SnO<sub>2</sub> [9,17], in agreement with the disappearance of Cu<sub>2</sub>O peaks in the XRD pattern of A-Cu/SnO<sub>2</sub> (Figure 3). Figure 4b shows the high-resolution Sn 3d spectra for the samples. Two peaks at 494.9 and 486.5 eV, corresponding to Sn 3d<sub>5/2</sub> and Sn 3d<sub>3/2</sub>, are assigned to the Sn(IV)/Sn(II) species (indistinguishable) [17,25,26]. For the Cu/SnO<sub>2</sub> electrode, there is a slight decrease of peak intensity, indicating the mild reduction of tin oxide. Different from Cu/SnO<sub>2</sub>, A-Cu/SnO<sub>2</sub> presents another two peaks at 491.7 and 483.1 eV that correspond to Sn(0) [25,26]. This reveals that SnO<sub>2</sub> particles on A-Cu/SnO<sub>2</sub> are reduced more deeply than that on Cu/SnO<sub>2</sub> under the same condition, evidenced by the *I-t* curves during pre-reduction process (Figure S6). The higher reactivity of A-Cu/SnO<sub>2</sub> under the reduction potential might be attributed to the fact that the growth of copper oxides makes the dense SnO<sub>2</sub> layer slacked off during annealing. According to the above results, it is demonstrated that Cu/SnO<sub>2</sub> mainly consists of partially reduced oxides SnO<sub>x</sub> on Cu foam, while for A-Cu/SnO<sub>2</sub>, the main components on Cu foam are Sn-SnO<sub>x</sub>-CuO<sub>x</sub>. The distinctive composition between Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> would give rise to the different CO<sub>2</sub> reduction activity and product distribution.



**Figure 4.** (a) Cu 2p X-ray photoelectron spectroscopy (XPS) spectra, (b) Sn 3d XPS spectra for Cu/SnO<sub>2</sub>, A-Cu/SnO<sub>2</sub>.

## 2.2. LSV Analysis for Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub>

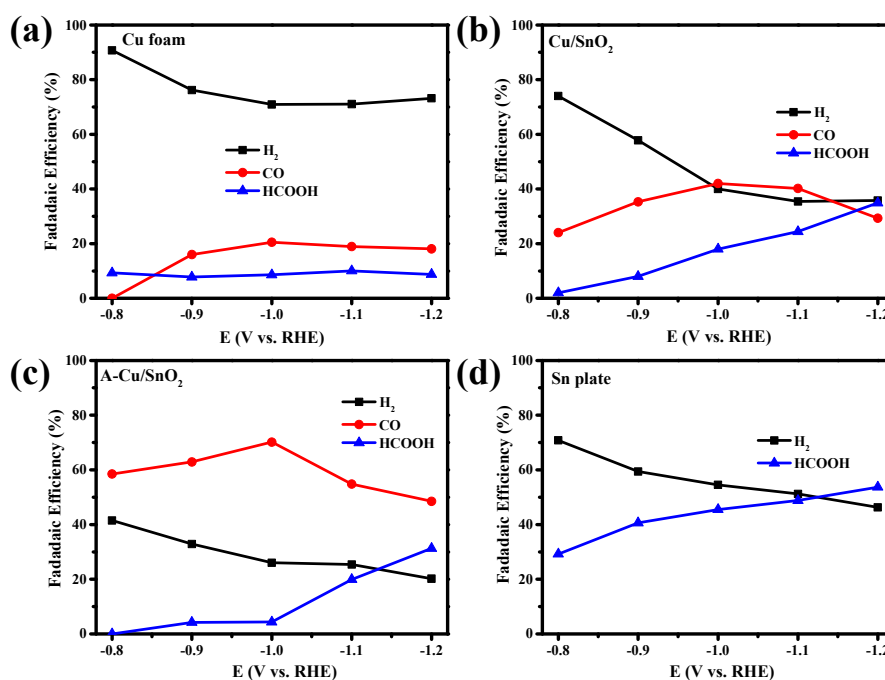
Linear scan voltammetry (LSV) tests were performed on Cu foam, Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub>. The results are shown in Figure 5. The solid and dashed lines represent the cathodic current density curves obtained in CO<sub>2</sub>-saturated and N<sub>2</sub>-saturated 0.1 M KHCO<sub>3</sub> solutions, respectively. The more dramatic current increase in the CO<sub>2</sub>-saturated electrolyte indicates that the reduction of CO<sub>2</sub> is catalytically more favorable relative to H<sub>2</sub>O reduction. Thus, it is obvious that they all exhibit activity toward CO<sub>2</sub> reduction with the increased activity in sequence: A-Cu/SnO<sub>2</sub> > Cu/SnO<sub>2</sub> > Cu foam. Besides this, the current densities in N<sub>2</sub> atmosphere on Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> are much weaker than that on Cu foam, indicating hydrogen evolution reaction is effectively suppressed. This could be attributed to the fact that H binding sites are inhibited due to the presence of Sn species [15,27].



**Figure 5.** The linear scan voltammetry (LSV) tests on Cu foam, Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> with a potential range from 0.2 V to −1.4 V (vs. reversible hydrogen electrode—RHE) at a scan rate of 50 mV/s in a N<sub>2</sub>-saturated and a CO<sub>2</sub>-saturated 0.1 M KHCO<sub>3</sub> electrolyte.

### 2.3. CO<sub>2</sub> Reduction Activity and Product Selectivity on Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub>

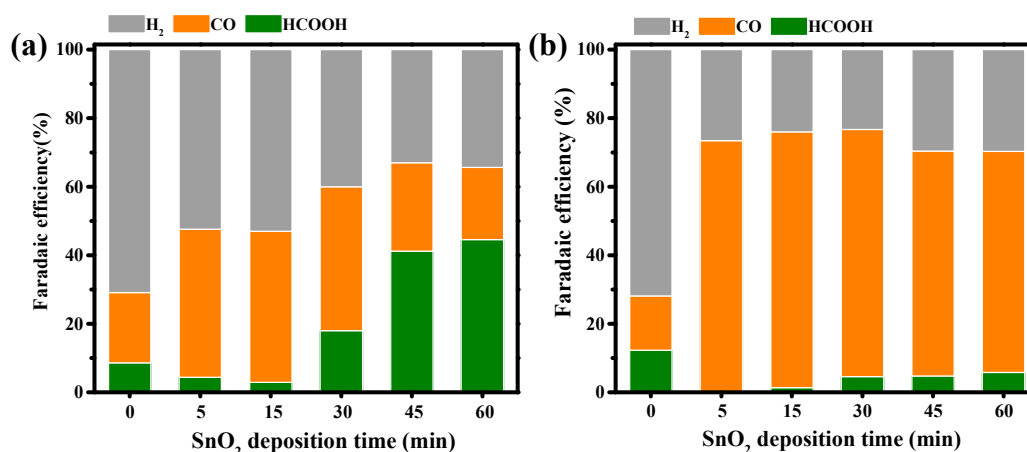
The product distributions of Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> for ERC are further evaluated under different potentials (−0.8 V to −1.2 V vs. RHE) in CO<sub>2</sub>-saturated 0.1 M KHCO<sub>3</sub> solution, respectively. The control experiments are also conducted on Cu foam and Sn plate. The I-t curves and the average current densities at different potentials for four electrodes are shown in Figure S7 and Table S3. The calculated FEs of H<sub>2</sub>, CO and HCOOH are compared in Figure 6. The Cu foam electrode (Figure 6a) primarily produces H<sub>2</sub> with a small amount of CO and HCOOH (total FEs, 30%) throughout a broad potential range (from −0.9 to 1.2 V vs. RHE). In contrast, Cu/SnO<sub>2</sub> (Figure 6b) shows a much-decreased FE of H<sub>2</sub> in the investigated potential range, indicating hydrogen evolution reaction is effectively suppressed after SnO<sub>2</sub> decoration. Besides this, at the low potential of −0.8 V, Cu foam shows the highest H<sub>2</sub> FE of 90% and nearly 10% HCOOH FE. In contrast, Cu/SnO<sub>2</sub> gives 75% of H<sub>2</sub> FE and 25% of CO FE. This clearly demonstrates that Cu/SnO<sub>2</sub> has higher CO<sub>2</sub> reduction activity and CO selectivity than Cu foam. Furthermore, when comparing with Sn plate (Figure 6d), it is observed that the potential dependent H<sub>2</sub> FE and HCOOH FE on Cu/SnO<sub>2</sub> are very similar to that of Sn plate, likely indicating the existence of active sites functioning as metal Sn. In the case of A-Cu/SnO<sub>2</sub>, also a SnO<sub>2</sub> decoration Cu electrode but with an additional annealing step, a predominantly higher selectivity to CO and a significant decrease of FEs of H<sub>2</sub> and HCOOH are observed, especially at the cathodic region from −0.8 to −1.0 V vs. RHE. Importantly, nearly 60% CO FE is obtained at −0.8 V while H<sub>2</sub> FE decreases to ~40% and little HCOOH forms. This result indicates that A-Cu/SnO<sub>2</sub> has even higher CO<sub>2</sub> reduction activity and CO selectivity than Cu/SnO<sub>2</sub>. Notably, the trend of the products on A-Cu/SnO<sub>2</sub> is consistent with the reported Cu-Sn catalysts showing Sn-Cu synergistic effect, such as Sn decorated oxide-derived Cu [16], tin nanoparticles-decorated Cu<sub>2</sub>O nanowires [17] and core/shell Cu/SnO<sub>2</sub> (thinner shell 0.8 nm) [24]. Therefore, we note from the above results that the Sn-Cu synergistic effect may play a key role for CO<sub>2</sub> to CO conversion selectively on Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub>. This effect may be explained by several studies on the DFT calculation for Cu-Sn catalysts [6,15,27]. The Sn atom can alter the adsorption sites on the surface of Cu, disfavoring the adsorption of H and leaving the adsorption of CO relatively unperturbed. Thus, it diminishes the hydrogenation capability (selectivity toward H<sub>2</sub> and HCOOH) while hardly affecting the CO formation, leading to the improved FE of CO.



**Figure 6.** The faradaic efficiency of H<sub>2</sub>, CO and HCOOH on (a) Cu foam, (b) Cu/SnO<sub>2</sub>, (c) A-Cu/SnO<sub>2</sub> and (d) Sn plate at various potentials in 0.1 M KHCO<sub>3</sub>.

We can also understand the Sn effect for altering the product distribution of Cu from the mechanistic pathway for CO<sub>2</sub> reduction. Generally, the mechanism for electrochemical reduction of CO<sub>2</sub> on metal electrodes is believed to start with a rate-determining initial electron transfer to CO<sub>2</sub> to form a surface-adsorbed  $\cdot\text{CO}_2^-$  intermediate [6,26,28,29]. For the electrodes Cu foam, Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub>, their CO partial current density Tafel plots (Figure S8) show the slope of 143.5 mV/dec, 125.9 mV/dec and 119.1 mV/dec, respectively, indicating the above mechanism could be applied. The following step is the protonation of  $\cdot\text{CO}_2^-$  through a second proton-electron pair. Competing rate-determining steps, protonation at C versus O of  $\cdot\text{CO}_2^-$ , may determine the HCOOH vs. CO selectivity. In other words, the selectivity of CO and HCOOH depends on the binding strength of key intermediate  $\cdot\text{COOH}$  for CO production and the key intermediate  $\cdot\text{OCHO}$  for HCOOH production. Referring to the DFT calculation about the selectivity for CO<sub>2</sub> reduction to HCOOH and CO on metal electrodes [15], Sn is the metal near the peak of both the  $\cdot\text{COOH}$  and  $\cdot\text{OCHO}$  volcanoes, whereas  $\cdot\text{OCHO}$  interacts more strongly with Sn surface than  $\cdot\text{COOH}$ , steering the selectivity to HCOOH over CO for Sn. In contrast, Cu is the metal having a medium  $\cdot\text{COOH}$  binding energy and sitting on the weak-binding side of the  $\cdot\text{OCHO}$  volcano, producing hydrocarbons except the CO and HCOOH with low selectivity. Doping the copper with Sn species would result in the changes of the binding energy of the related intermediate [11]. Thus, the Sn-Cu effect could be optimized by tuning the relative amount of Cu and Sn to an optimal value. The difference of CO<sub>2</sub> reduction activity and product distribution between Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> might be a result from different density of Cu-Sn interface on the surface, reflected from the different content of Cu atoms in SnO<sub>2</sub> layer by XPS analysis (Cu 17.1%, Sn 23.8% for Cu/SnO<sub>2</sub> and Cu 26.0%, Sn 10.1% for A-Cu/SnO<sub>2</sub>) [17,24]. Besides this, the increase of Cu atoms on the surface for A-Cu/SnO<sub>2</sub> could be evidenced by the presence of the obvious copper redox feature in cyclic voltammograms (CVs) curves, as illustrated in Figure S9. Further work should focus on operando spectroscopic characterizations to elucidate the exact active sites and the role of the Sn-Cu synergistic effect to determine the pathway of CO<sub>2</sub> reduction [27,30].

For understanding the Sn-Cu catalysis on Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> systematically, besides the above investigated electrodes Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> (deposition time, 30 min), other electrodes were fabricated with the short deposition time of 5 min and 15 min, and long deposition time of 45 min and 60 min. Their SEM images and EDX results are displayed in Figures S10–S13 and Table S4. The FEs of the products for these electrodes are illustrated in Figure 7a,b.



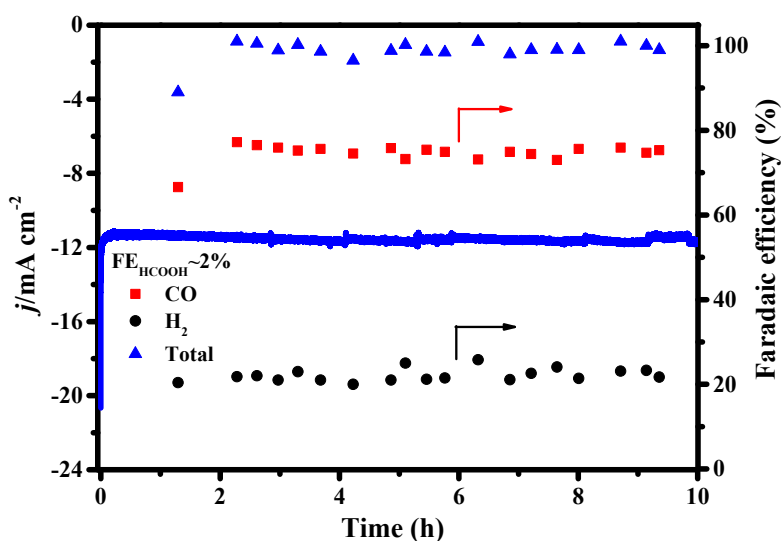
**Figure 7.** Comparison of FEs of H<sub>2</sub>, CO and HCOOH for (a) Cu/SnO<sub>2</sub> and (b) A-Cu/SnO<sub>2</sub> electrodes with different SnO<sub>2</sub> deposition time at −1.0 V vs. RHE in CO<sub>2</sub>-saturated 0.1 M KHCO<sub>3</sub>.

For Cu/SnO<sub>2</sub> electrodes with different SnO<sub>2</sub> deposition time, FE of HCOOH increases with the increasing deposition time, accompanying the decrease tendency for FE of H<sub>2</sub>. FE of CO is at a higher level when the deposition time is within 30 min. A sharp decrease of CO FE appears at the deposition time of 45 min, and the decrease continues with the prolonged deposition time, which is



along with sharp increase of HCOOH FE. It is obvious that there is a selectivity transformation from CO to HCOOH at a deposition time of 45 min, at which the surface of Cu foam becomes completely covered by deposited SnO<sub>2</sub>. It reveals a SnO<sub>2</sub> coverage-dependent catalysis on Cu/SnO<sub>2</sub> electrodes, similar to the SnO<sub>2</sub> thickness-dependent catalysis for core/shell Cu/SnO<sub>2</sub> in Sun's work [23]. It is likely demonstrated that Sn-Cu synergistic effect doesn't work without a relative amount of Cu atom on the SnO<sub>2</sub> surface. By contrast, there is no apparent shift from one dominant product to another for the A-Cu/SnO<sub>2</sub> electrodes with different SnO<sub>2</sub> deposition time, which all present the dominant CO formation ( $FE_{CO}$ , 70~75%), less H<sub>2</sub> formation ( $FE_{H_2}$ , 22~30%) and the least formation of HCOOH ( $FE_{HCOOH}$ , <5%), which reflects a characteristic product selectivity caused by Sn-Cu synergistic effect, as previously reported for Sn-modified Cu electrodes [16–18]. It has been found from XRD and XPS results of A-Cu/SnO<sub>2</sub> (30 min) that annealing could cause the apparent increase of Cu content on the surface. Therefore, the similar product selectivity for A-Cu/SnO<sub>2</sub> electrodes with different deposition times also suggested the importance of the content of Cu atom in SnO<sub>2</sub> layer for the function of Sn-Cu synergistic effect.

Furthermore, the stability test is conducted on A-Cu/SnO<sub>2</sub> electrode with a deposition time of 15 min for 10 h under −1.0 V vs. RHE in CO<sub>2</sub>-saturated 0.1 M KHCO<sub>3</sub> solution. The result is shown in Figure 8. Obviously, the total current density is maintained well at −8.5 mA cm<sup>−2</sup>, and the selectivity for CO keeps steadily around 75% throughout the 10 h electrolysis. Besides this, by comparing the XRD (Figure S14) patterns and SEM images (Figure S15) of A-Cu/SnO<sub>2</sub> (15 min) before and after the 10 h electrolysis, it is revealed that the surface morphology and composition maintain well. The good stability should be ascribed to the large electrochemical active surface area (ECSA, shown in Figure S16), which could prevent the active sites on the surface from the contamination of impurities in solution or C deposits formed during CO<sub>2</sub> reduction [31,32].



**Figure 8.** Long-term stability test for A-Cu/SnO<sub>2</sub> (15 min) electrode at −1.0 V vs. RHE for 10 h in CO<sub>2</sub>-saturated 0.1 M KHCO<sub>3</sub> solution.

### 3. Materials and Methods

#### 3.1. Materials

Copper foil (99.9%, 0.3 mm thickness, IncoUnion, Tianjin, China) was used to prepare electrode substrate. Tin foil (99.9%, 0.3 mm thickness, IncoUnion, Tianjin, China) and phosphoric acid (H<sub>3</sub>PO<sub>4</sub>, 85%, Yuanli, Taiwan, China) were used for electropolishing copper foil. Copper(II) sulphate pentahydrate (CuSO<sub>4</sub>·5H<sub>2</sub>O, 99%, J&K, India) and sulfuric acid (H<sub>2</sub>SO<sub>4</sub>, 98%, Yuanli, Taiwan, China) were used in electrodeposition of copper foam. Tin foil (99.9%, 0.5 mm thickness, IncoUnion, Tianjin, China), tin(IV) chloride pentahydrate (SnCl<sub>4</sub>·5H<sub>2</sub>O, 99%, J&K, India), nitric acid (HNO<sub>3</sub>, 99%,

Yuanli, Tianjin, China) and sodium nitrate ( $\text{NaNO}_3$ , 99.9%, Aladin, Shanghai, China) were used in electrodepositing  $\text{SnO}_2$  film on Cu foam. Potassium bicarbonate ( $\text{KHCO}_3$ , 99.5%, J&K, India) was used as electrolyte in electrochemical reduction of  $\text{CO}_2$ .

### 3.2. Electrode Preparation

#### 3.2.1. Fabrication of Cu Foam

The Cu foil ( $1.0 \times 1.0 \text{ cm}^2$ ) was mechanically polished with 2000 grade sandpaper, followed by electropolishing in an 85% phosphoric acid electrolyte and washing with acetone and deionized water. The back of the Cu foil was encapsulated with epoxy resin. The Cu foam was deposited on the pretreated Cu foil via dynamic hydrogen template method [5] using a current density of  $-3.0 \text{ A cm}^{-2}$  and deposition time of 15 s in the electrolyte consisting of 0.2 M  $\text{CuSO}_4$  and 1.5 M  $\text{H}_2\text{SO}_4$  aqueous solution. The resultant Cu foam electrode was rinsed with DI water and dried at room temperature. For comparison, the as-prepared Cu foam electrode was annealed in a muffle furnace at  $200^\circ\text{C}$  for 6 h. The annealed Cu foam sample is named A-Cu foam.

#### 3.2.2. Fabrication of Cu/ $\text{SnO}_2$ and A-Cu/ $\text{SnO}_2$ Electrodes

$\text{SnO}_2$  film was electrodeposited on the Cu foam electrodes in a two-electrode cell with Sn foil ( $2.0 \times 2.0 \text{ cm}^2$ ) as the anode. The electrolyte consisted of an aqueous solution of 0.02 M  $\text{SnCl}_4$ , 0.1 M  $\text{NaNO}_3$  and 0.075 M  $\text{HNO}_3$ . Electrodepositions were performed at  $-0.3 \text{ V}$  while changing deposition time (5, 15, 30, 45 and 60 min). The typical samples were prepared with the deposition time of 30 min. Then the electrochemical pre-reduction was performed in a  $\text{CO}_2$ -saturated 0.1 M  $\text{KHCO}_3$  solution at  $-0.5 \text{ V}$  vs. RHE for one hour to obtain the Cu/ $\text{SnO}_2$  electrode.

A-Cu/ $\text{SnO}_2$  electrodes were obtained through the same procedure but with an additional annealing step between the electrodepositing and pre-reduction. Annealing was conducted in a muffle furnace at  $200^\circ\text{C}$  for 6 h with static air.

### 3.3. Physical and Chemical Characterization

The microstructure of the electrodes was tested by X-ray diffraction (XRD, Rigaku D/MAX-2500 diffractometer, Tokyo, Japan) with Cu  $\text{K}\alpha$  radiation that was collected from  $10^\circ$  to  $80^\circ$  at a scan rate of  $6^\circ$  per min. The morphologies of the electrocatalysts were observed by scanning electron microscopy (SEM, Hitachi S-4800, Tokyo, Japan) in conjunction with energy-dispersive X-ray spectroscopy (EDS). X-ray photoelectron spectroscopy (XPS) was performed using a PHI 1600 (PerkinElmer, Waltham, MA, USA) analyzer with X-ray excitation provided by an Al  $\text{K}\alpha$  X-ray source, and all the XPS spectra were calibrated by  $\text{C}1\text{s}_{\frac{1}{4}}$  binding energy, which was  $284.5 \text{ eV}$ .

### 3.4. Electrochemical Measurements

All electrochemical measurements were carried out in a gastight glass H-type electrolytic cell, separated by a proton exchange membrane Nafion 115 (Dupont, Midland, MI, USA) between the anode cell and cathode cell. The electrolyte consisted of a 0.1 M  $\text{KHCO}_3$  solution. The cathode and anode compartments contained 90 mL and 50 mL of electrolyte, respectively. The  $\text{CO}_2$  electroreduction measurements were carried out with an electrochemical workstation (AutoLab 302N, Herisau, Switzerland). A Pt Foil ( $1.0 \times 2.0 \text{ cm}^2$ ) and a  $\text{Hg}_2\text{Cl}_2/\text{Hg}$ /saturated KCl electrode (SCE) served as counter electrode and reference electrode respectively. The potentials were measured against SCE and converted to the reversible hydrogen electrode (RHE) potentials by the following equation:  $E_{\text{RHE}} (\text{V}) = E_{\text{SCE}} (\text{V}) + 0.240 \text{ V} + 0.0591 \text{ V} \times \text{pH}_{\text{electrolyte}}$ . Herein, the pH values of  $\text{N}_2$ -saturated and  $\text{CO}_2$ -saturated 0.1 M  $\text{KHCO}_3$  electrolytes are determined as 7.0 and 6.8, respectively. Therefore, the compensation potential of 0.01 V due to pH bias is taken into account to determine the applied potentials in LSV tests and  $\text{CO}_2$  reduction electrolysis experiment. LSV tests were performed at a potential range from 0.0 V to  $-1.4 \text{ V}$  vs. RHE.

During potentiostatic electrolysis CO<sub>2</sub> reduction, the cathodic electrolyte was saturated with CO<sub>2</sub> at a flow rate of 20 mL min<sup>−1</sup> continuously and stirred at the rate of 300 rpm. The obtained gas products were collected by gas bags and detected by gas chromatography (GC, Agilent 7890B). The liquid products were analyzed using a 700 MHz 1H 1D liquid NMR spectrometer (Bruker Avance) at 25 °C. The 1H 1D spectrum was measured with water suppression by a pre-saturation method. The content of formic acid in the liquid product was analyzed using dimethyl sulfoxide as an internal standard.

The FE of the product reflects the selectivity of the product, and is calculated by Equations (1)–(4),

$$i_{\text{H}_2 \text{ or CO}} = V_{\text{H}_2 \text{ or CO}} \times q \times \frac{2Fp_0}{RT} \quad (1)$$

$$FE_{\text{H}_2 \text{ or CO}} = \frac{i_{\text{H}_2 \text{ or CO}}}{i_{\text{Total}}} \times 100\% \quad (2)$$

$$Q_{\text{HCOOH}} = 2c_{\text{HCOOH}}VF \quad (3)$$

$$FE_{\text{HCOOH}} = \frac{Q_{\text{HCOOH}}}{Q_{\text{Total}}} \quad (4)$$

where  $i_{\text{H}_2 \text{ or CO}}$  is partial current density of H<sub>2</sub> or CO,  $V_{\text{H}_2 \text{ or CO}}$  is volume concentration of H<sub>2</sub> or CO quantified by GC,  $q$  is flow rate of CO<sub>2</sub>,  $i_{\text{Total}}$  is the measured average current,  $F$  is Faradaic constant (96,485.3 C/mol),  $p_0$  is pressure,  $T$  is room temperature and  $R$  is ideal gas constant (8.314 J mol<sup>−1</sup> K<sup>−1</sup>),  $c_{\text{HCOOH}}$  is the molar concentration of HCOOH quantified by NMR,  $V$  is the total volume of the catholyte and  $Q_{\text{Total}}$  is the total amount of charge in the electrolysis based on  $I$ - $t$  Curves.

#### 4. Conclusions

In conclusion, we successfully fabricated porous Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> electrodes by deposition-electroreduction and deposition-annealing-electroreduction procedures, respectively. The characterizations by SEM, XRD, XPS and EDX demonstrate that they both maintained the porous structure well but possess the significantly different surface compositions. Notably, in comparison with Cu/SnO<sub>2</sub>, A-Cu/SnO<sub>2</sub> exhibits a significant enhancement in terms of CO<sub>2</sub> reduction activity and CO selectivity. Besides this, A-Cu/SnO<sub>2</sub> electrodes with different deposition time of SnO<sub>2</sub> present the characteristic Sn-Cu synergistic catalysis with a feature of dominant CO formation (CO faradaic efficiency, 70~75%), the least HCOOH formation (HCOOH faradaic efficiency, <5%) and the remarkable suppression of hydrogen evolution reaction. In contrast, Cu/SnO<sub>2</sub> electrodes with different deposition time from SnO<sub>2</sub> exhibit a SnO<sub>2</sub> coverage-dependent catalysis—a shift from CO selectivity to HCOOH selectivity with the increasing deposited SnO<sub>2</sub> on Cu foam. The different catalytic performance between Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> might be attributed to the different content of Cu atoms in SnO<sub>2</sub> layer, which may affect the density of Cu-Sn interface on the surface. Our findings highlight the effects of the relative amount of metals on tuning the product distribution for Cu-based electrocatalysts toward ERC.

**Supplementary Materials:** The following are available online at <http://www.mdpi.com/2073-4344/9/5/476/s1>. Figure S1: The SEM image of Cu foam. Figure S2: The cross-sectional views of Cu/SnO<sub>2</sub>. Figure S3: SEM elemental mapping for (a) Cu/SnO<sub>2</sub> and (b) A-Cu/SnO<sub>2</sub> before pre-reduction. The table is EDX analysis identifying. Figure S4: XRD patterns of Cu Foil and Cu foam. Figure S5: XPS survey spectra of Cu/SnO<sub>2</sub>, A-Cu/SnO<sub>2</sub> before and after pre-reduction. Table S1: The content of Cu and Sn of Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> obtained from ICP-AES. Table S2: Summary of atomic percent of Cu/SnO<sub>2</sub> and A-Cu/SnO<sub>2</sub> before and after pre-reduction obtained from XPS and SEM-EDX elemental mapping. Table S3: The current density at different potentials obtained from Figure S13 on (a) Cu foam, (b) Cu/SnO<sub>2</sub>, (c) A-Cu/SnO<sub>2</sub> and (d) Sn plate. Table S4: Mass fraction and atomic fraction of Cu, Sn, O on the surface of the electrode with different deposition time of SnO<sub>2</sub> detected by SEM-EDS.

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